

**Amendments to the Specification:**

Please replace paragraph [0013] with the following rewritten paragraph:

[0013] In addition to the structure described above, according to an aspect of the present invention, the capacitor wire is formed as the same film as that for the electrodes forming the exterior circuit connection terminals and supplies a predetermined potential to the capacitor electrodes of the storage capacitors. In an aspect of the present invention, the "formed as the same film as that for" means that, in a manufacturing process of this electro-optical device, solid films for both the electrodes and the capacitor wire are formed at the same time and are then processed by predetermined patterning treatment (including, for example, photolithographic and etching steps) at the same time. Accordingly, the electrodes and the capacitor wire are formed ~~on~~as the same layer of the laminate structure composed of the data lines, scanning lines, pixel electrodes, and the like, and in addition, the electrodes and the capacitor wire are formed of the same material.